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(54) **METHOD AND APPARATUS TO DETERMINE INTEGRATED CIRCUIT TEMPERATURE**

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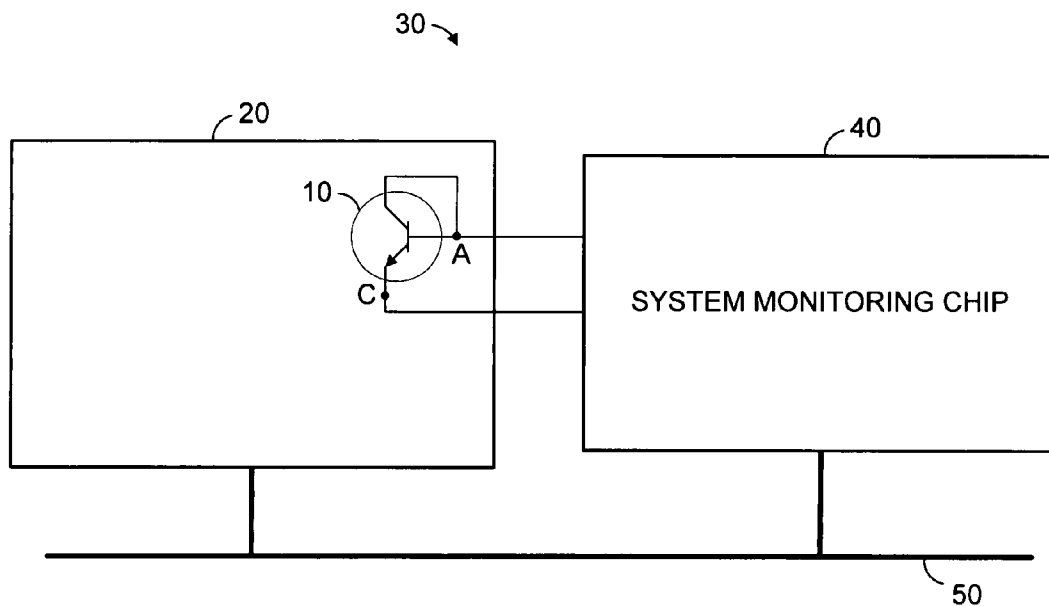(57)   **ABSTRACT**

A system may include a first diode and a device coupled to the first diode. The device may be adapted to transmit a first current through the first diode, to determine a first voltage across the first diode, the first voltage associated with the first current, to transmit a second current through the first diode, and to determine a second voltage across the first diode, the second voltage associated with the second current. The device may be further adapted to transmit a third current through the first diode, to determine a third voltage across the first diode, the third voltage associated with the third current, and to determine a temperature of the first diode based at least in part on the first voltage, the second voltage and the third voltage.
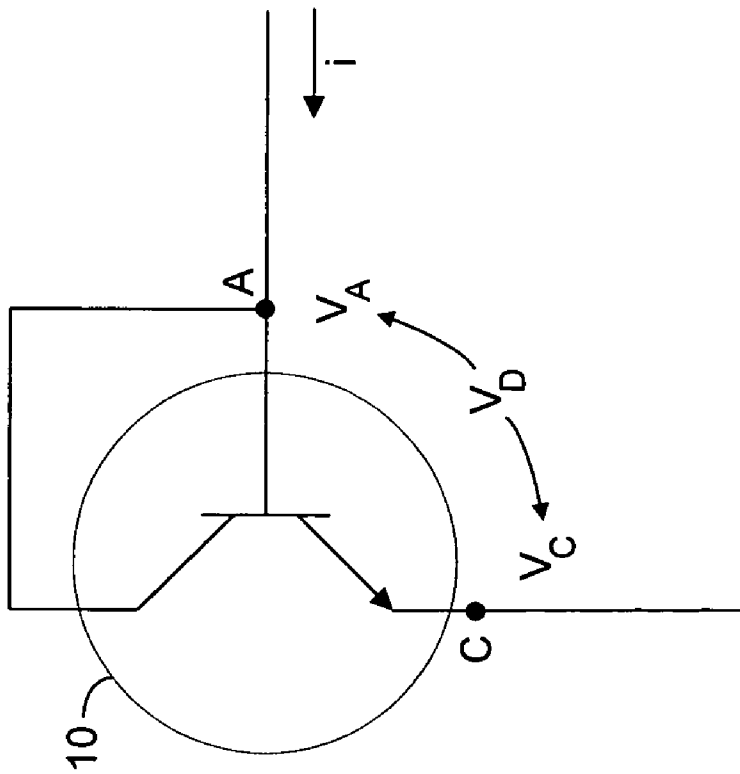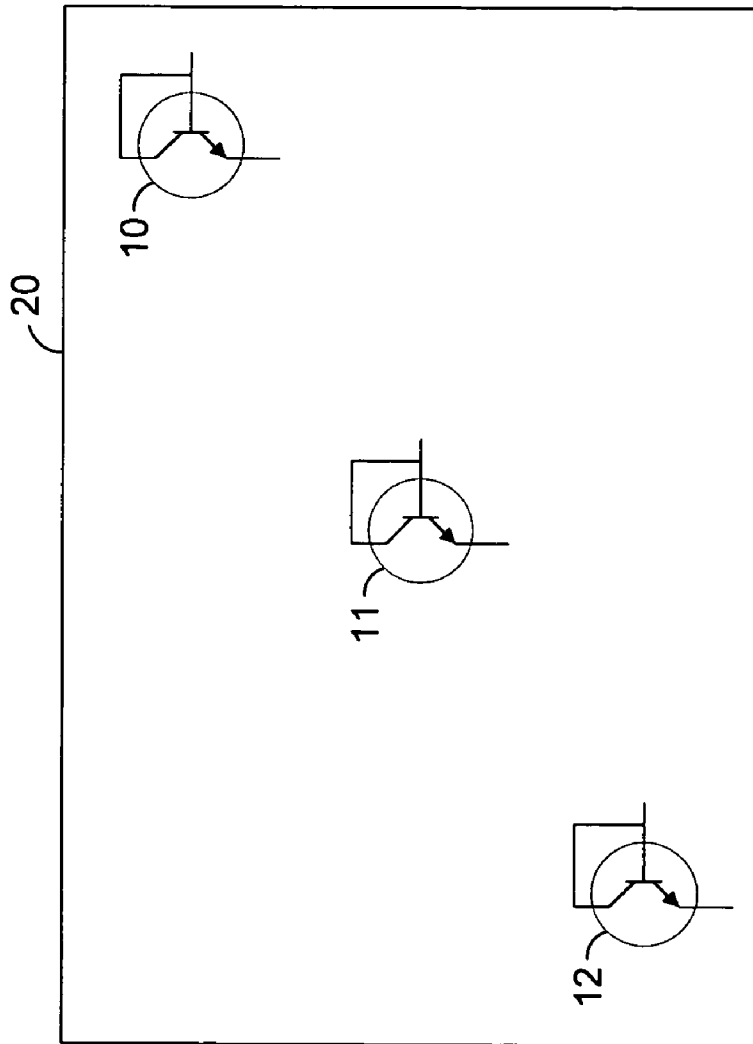
30

20

10

A

C

40

SYSTEM MONITORING CHIP

50

FIG. 1

FIG. 2

FIG. 3

FIG. 4

60

TRANSMIT A FIRST CURRENT
THROUGH A DIODE — 61

DETERMINE A FIRST VOLTAGE
ACROSS THE DIODE ASSOCIATED
WITH THE FIRST CURRENT — 62

TRANSMIT A SECOND CURRENT
THROUGH THE DIODE — 63

DETERMINE A SECOND VOLTAGE
ACROSS THE DIODE ASSOCIATED
WITH THE SECOND CURRENT — 64

TRANSMIT A THIRD CURRENT
THROUGH THE DIODE — 65

DETERMINE A THIRD VOLTAGE
ACROSS THE DIODE ASSOCIATED
WITH THE THIRD CURRENT — 66

DETERMINE A TEMPERATURE
BASED ON THE FIRST, SECOND,
AND THIRD VOLTAGES — 67
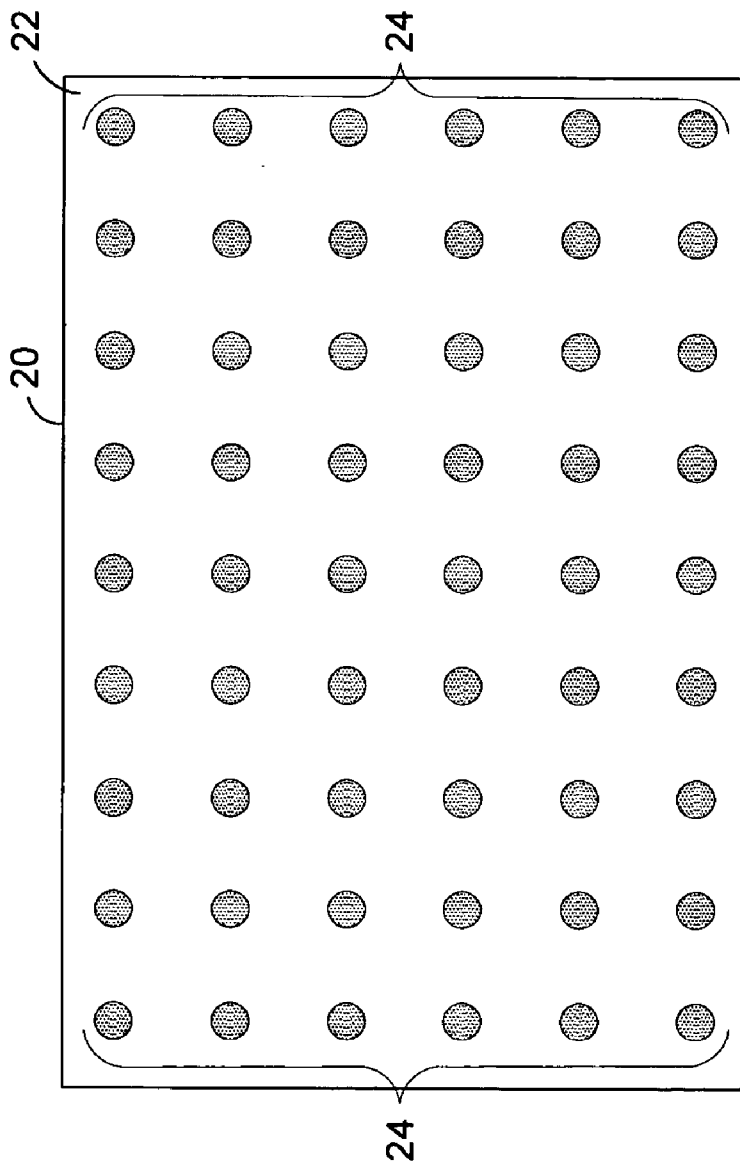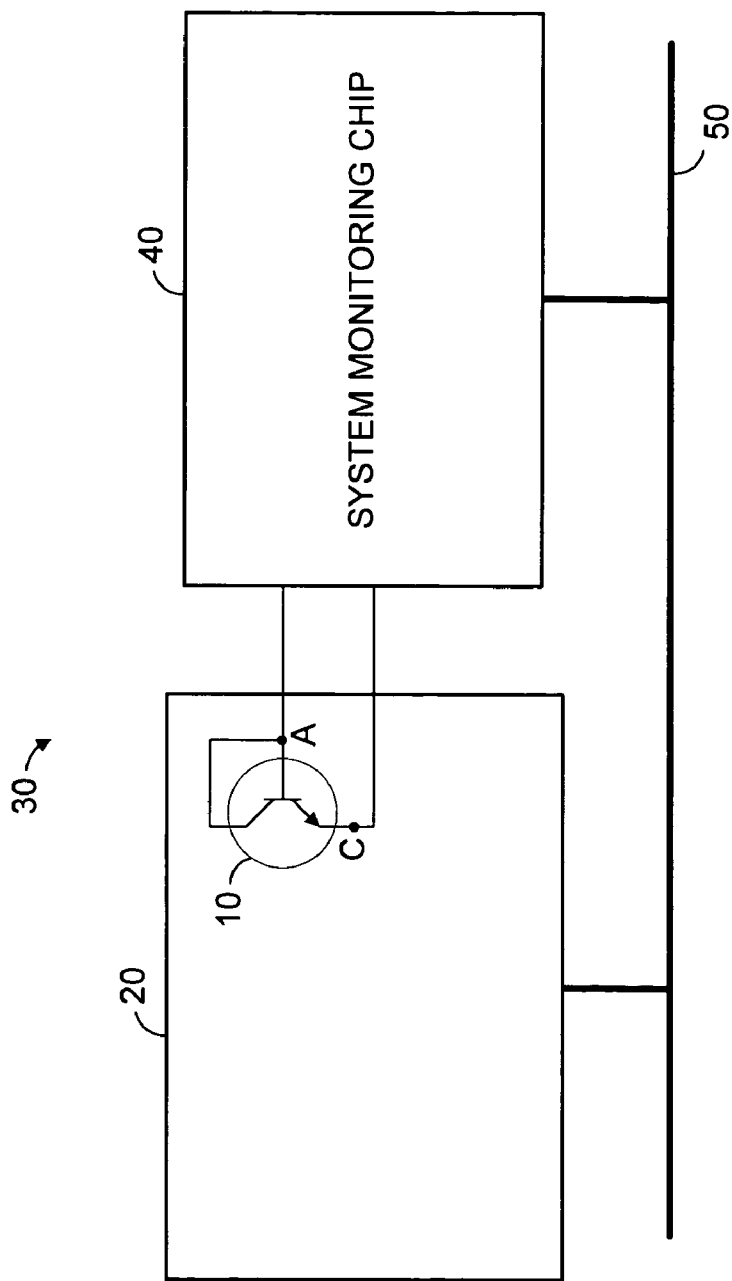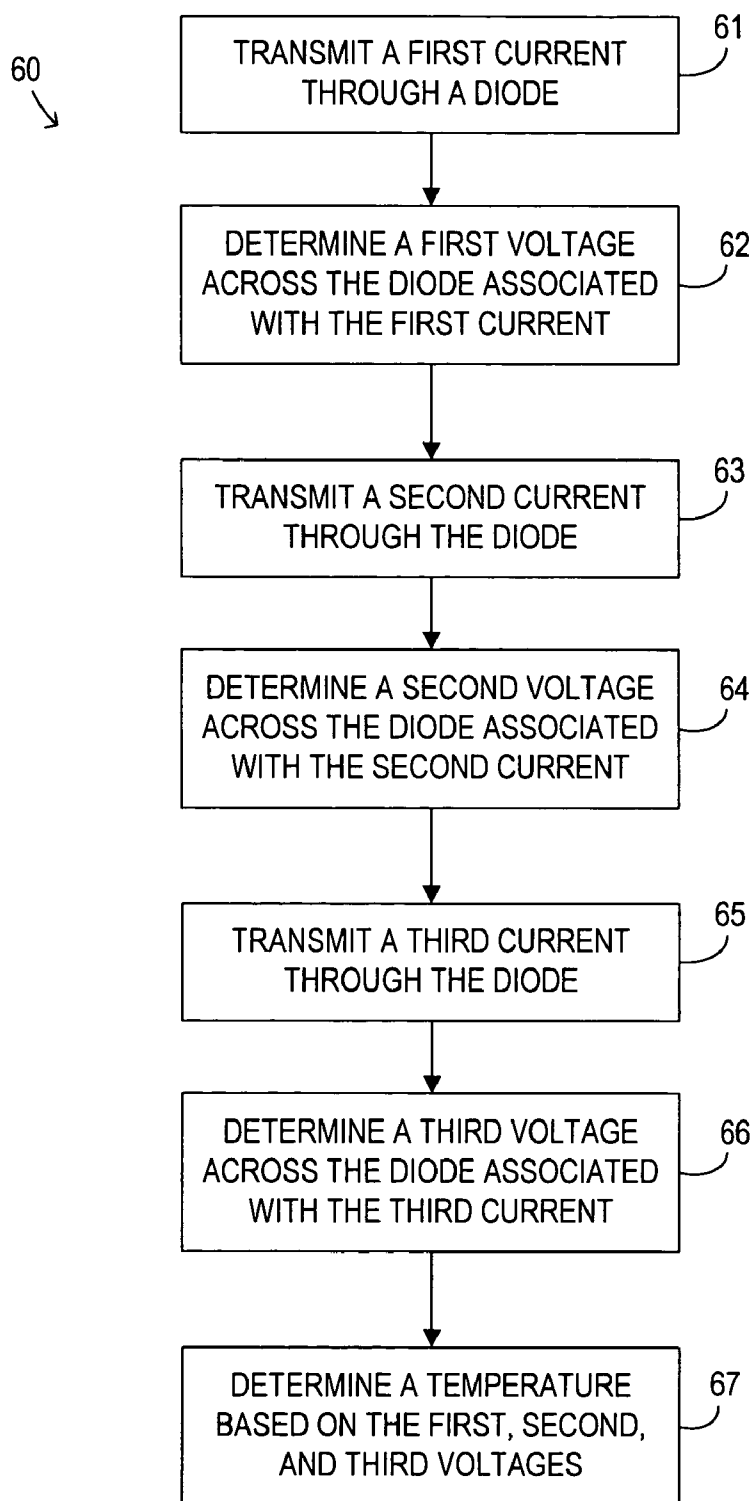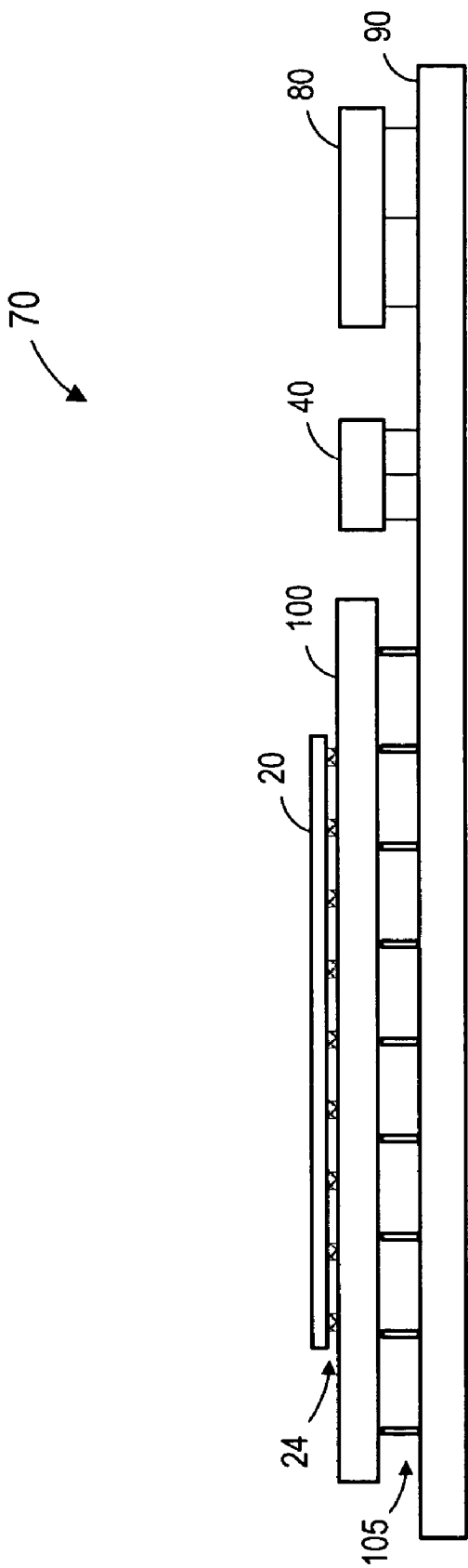
FIG. 5

FIG. 6

METHOD AND APPARATUS TO DETERMINE INTEGRATED CIRCUIT TEMPERATURE

BACKGROUND

[0001] An integrated circuit (IC) die includes a semiconductor substrate and various electronic devices integrated therewith. The electronic devices may generate heat during operation of the IC die. This heat may adversely affect the performance of the IC die, and in some cases may damage one or more of its integrated electronic devices. Conventional systems may determine the temperature of an IC die and control operator warnings, cooling devices, processing clocks and/or other temperature-related elements based on the determined temperature.

[0002] Some conventional systems determine an IC die temperature using a diode that is integrated into the die. In particular, these systems may apply two different currents to the diode, measure a voltage drop across the diode corresponding to each of the two currents, and determine the temperature of the diode based on the two currents, the two voltage drops, and the ideal diode equation. Many of these systems do not account for the equivalent series resistance (ESR, or R_s) of the diode and its associated trace, thereby reducing the accuracy of the determined temperature. Some systems attempt to approximate R_s and to incorporate the approximation into the determination of temperature. The approximated R_s may be a fixed value and/or may be calculated based on a predetermined temperature vs. trace resistivity curve.

BRIEF DESCRIPTION OF THE DRAWINGS

[0003] FIG. 1 is a schematic view of a diode according to some embodiments.

[0004] FIG. 2 is a block diagram of an IC die according to some embodiments.

[0005] FIG. 3 is a view of an IC die according to some embodiments.

[0006] FIG. 4 is a block diagram of an apparatus according to some embodiments.

[0007] FIG. 5 is a diagram of a process to determine a temperature according to some embodiments.

[0008] FIG. 6 is a diagram of a system according to some embodiments.

DETAILED DESCRIPTION

[0009] FIG. 1 is a schematic view of diode 10 for use in conjunction with some embodiments. Diode 10 may comprise a base-emitter junction of a substrate-connected PNP transistor. The substrate may be silicon according to some embodiments. Other suitable diodes may be used in conjunction with some embodiments.

[0010] FIG. 1 illustrates current i transmitted to diode 10. Current i generates voltage drop v_D across diode 10. Voltage drop v_D is equal to the difference between the voltage v_A at node A of diode 10 and the voltage v_C at node C. In this regard, node A is positioned at the anode of diode 10 and node C is positioned at the cathode of diode 10.

[0011] The base-emitter junction of diode 10 may be modeled by the ideal diode equation shown below:

$$i = I_s(e^{\frac{qV_D}{nkT}} - 1),$$

[0012] where I_s corresponds to the saturation current of diode 10, T corresponds to the temperature of diode 10, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with diode 10, and q corresponds to the charge of a electron. In some embodiments, n=1 for most IC fabrication technologies and n=2 for discrete components. Particular values used for the other variables may vary depending upon desired degrees of accuracy and/or preferred units.

[0013] FIG. 2 illustrates IC die 20 according to some embodiments. IC die 20 includes integrated electrical devices and may be fabricated using any suitable substrate material and fabrication techniques. IC die 20 may provide one or more functions. In some embodiments, IC die 20 comprises a microprocessor chip having a silicon substrate.

[0014] IC die 20 includes diode 10. IC die 20 also includes diodes 11 and 12, which may comprise identical instances of diode 10. Diodes 10, 11, and 12 may be used to determine a temperature at various locations of IC die 20, and may therefore be referred to as thermal diodes. Although shown on a surface of die 20, one or more of diodes 10, 11 and 12 may be integrated within die 20 and located under layers of dielectric, metallization, substrate, and/or other materials. IC die 20 may comprise more or fewer thermal diodes than shown in FIG. 2, and one or more of the thermal diodes may somehow differ from one or more of the other thermal diodes.

[0015] FIG. 3 shows external side 22 of IC die 20 according to some embodiments. Side 22 includes electrical contacts 24. Electrical devices that are integrated into IC die 20 may reside between a substrate of IC die 20 and electrical contacts 24. In some embodiments, such a substrate resides between the electrical devices and electrical contacts 24.

[0016] Electrical contacts 24 may be electrically coupled to the electrical devices that are integrated into IC die 20. In some embodiments, one or more of electrical contacts 24 may be coupled to node A of diode 10 and one or more of electrical contacts 24 may be electrically coupled to node C of diode 10. One or more of electrical contacts 24 may also be electrically coupled to nodes of diodes 11 and 12.

[0017] Electrical contacts 24 may comprise gold and/or nickel-plated copper contacts fabricated upon IC die 20. Electrical contacts 24 may comprise Controlled Collapse Chip Connect (C4) solder bumps. Although electrical contacts 24 are shown as having substantially circular cross sections, in other embodiments one or more of electrical contacts 24 have cross sections of different and/or varying shapes. Electrical contacts 24 may be recessed under, flush with, or extending above side 22 of IC die 20.

[0018] FIG. 4 illustrates apparatus 30 according to some embodiments. Apparatus 30 comprises IC die 20 and system monitoring chip 40. System monitoring chip 40 is coupled to nodes A and C of diode 10. According to some embodiments, system monitoring chip 40 may transmit a current i

to diode **10** and may determine a voltage VD associated with the transmitted current. System monitoring chip **40** may be directly coupled to nodes A and C as shown in **FIG. 4** or may be coupled through intermediate devices according to some embodiments. For example, a signal transmitted from monitoring chip **40** may pass through a motherboard, a socket, an IC package and electrical contacts **24** before reaching diode **10**.

[0019] System monitoring chip **40** may comprise an IC that monitors remote temperatures, its own internal temperature, supply voltages associated with IC die **20**, cooling fan speed, and/or other parameters. System monitoring chip **40** may also control cooling fan speed based on the monitored parameters and on specified threshold temperatures.

[0020] System monitoring chip **40** may be coupled to IC die **20** and to other unshown elements via bus **50**. The unshown elements may include a memory for storing parameter values determined by chip **40**, threshold values used by chip **40**, or other data. Bus **50** may comprise a system monitoring bus or any other suitable bus.

[0021] In operation, system monitoring chip **40** may transmit a first current through diode **10**, determine a first voltage across diode **10**, the first voltage associated with the first current, transmit a second current through diode **10**, and determine a second voltage across diode **10**, the second voltage associated with the second current. Chip **40** may also transmit a third current through diode **10**, determine a third voltage across diode **10**, the third voltage associated with the third voltage, and determine a temperature of diode **10** based at least in part on the first voltage, the second voltage and the third voltage. Such operation will be described in detail with respect to **FIG. 5**.

[0022] **FIG. 5** is a diagram of process **60** according to some embodiments. Process **60** is described below as being executed by system monitoring chip **40**. Process **60** may be processed by any number of devices, including or excluding chip **40**. In some embodiments, process **60** is executed by an A/D converter and a microcontroller. Process **60** may also be executed by a dedicated temperature sensor. Process **60** may be executed by one or more electrical devices integrated into die **20** according to some embodiments. Process **60** may be executed before, during or after during operation of IC die **20**.

[0023] Initially, at **61**, a first current i_1 is transmitted through diode **10**. First current i_1 may be substantially equal to a minimum current specification of IC die **20**. In some embodiments, system monitoring chip **40** transmits first current i_1 to node A through one or more of electrical contacts **24** that are coupled to node A of diode **10**. Current i_1 results in a voltage v_{A1} and a voltage v_{C1} at respective nodes A and C of diode **10**. As described above, voltage $v_{D1} = v_{A1} - v_{C1}$ and therefore is associated with current i_1.

[0024] Voltage v_{D1} across diode **10** is determined at **62**. System monitoring chip **40** may determine voltage v_{D1} by determining voltage v_{A1} and voltage v_{C1}, and by determining a difference between voltage v_{A1} and voltage v_{C1}.

[0025] A second current i_2 is transmitted through diode **10** at **63**. Second current i_2 may be substantially equal to a maximum current specification of IC die **20**. System monitoring chip **40** may transmit i_2 to diode **10**, resulting in a voltage v_{A2} and a voltage v_{C2} at respective nodes A and C.

At **64**, voltage v_{D2} across diode **10** is determined as the difference between voltage v_{A2} and voltage v_{C2}.

[0026] Next, at **65**, a third current i_3 is transmitted through diode **10**. In some embodiments, a magnitude of third current i_3 is substantially equal to the geometric mean of the magnitude of first current i_1 and the magnitude of second current i_2. For example, system monitoring chip **40** may include current multipliers to transmit currents i_1, i_2 and i_3 of 10, 30, and 90 μA using a 1×, 3×, and 9× ratio, or 6, 24, 96 μA using a 1×, 4×, and 16× ratio. System monitoring chip **40** may transmit i_3 to diode **10**, resulting in a voltage v_{A3} and a voltage v_{C3} at respective nodes A and C. Voltage v_{D3} across diode **10** is determined at **66** as the difference between voltage v_{A3} and voltage v_{C3}.

[0027] A temperature is determined at **67** based on voltages v_{D1}, v_{D2}, and v_{D3}. The temperature may correspond to a temperature of diode **10**. In some embodiments, the determination of the temperature at **67** includes a determination of the ESR of a path associated with diode **10** based on voltages v_{D1}, v_{D2}, and v_{D3}. The following equations show the derivation of one equation for determining ESR according to some embodiments.

[0028] From the diode equation shown above:

$$\frac{i_1}{i_2} = \frac{I_s\left(e^{\frac{v_{D1}q}{knT}} - 1\right)}{I_s\left(e^{\frac{v_{D2}q}{knT}} - 1\right)} = \frac{e^{\frac{v_{D1}q}{knT}} - 1}{e^{\frac{v_{D2}q}{knT}} - 1}$$

[0029] Removing the (−1) terms for simplification results in:

$$\frac{i_1}{i_2} = \frac{e^{\frac{v_{D1}q}{knT}}}{e^{\frac{v_{D2}q}{knT}}}$$

$$\ln\left(\frac{i_1}{i_2}\right) = \ln\left(\frac{e^{\frac{v_{D1}q}{knT}}}{e^{\frac{v_{D2}q}{knT}}}\right) = \ln\left(e^{\frac{v_{D1}q}{knT}}\right) - \ln\left(e^{\frac{v_{D2}q}{knT}}\right) = \frac{v_{D1}q}{knT} - \frac{v_{D2}q}{knT}$$

[0030] Solving for T:

$$T = \left(\frac{q}{kn\ln\left(\frac{i_1}{i_2}\right)}\right)(v_{D1} - v_{D2}) \qquad \text{[Equation A]}$$

or

$$(v_{D1} - v_{D2}) = T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right).$$

[0031] Therefore,

$$v_{D3} - v_{D2} = T\frac{kn}{q}\ln\left(\frac{i_3}{i_2}\right) = T\frac{kn}{q}\ln\left(\frac{\sqrt{i_1 \cdot i_2}}{i_2}\right) = T\frac{kn}{q}\ln\left(\left(\frac{i_1}{i_2}\right)^{\frac{1}{2}}\right) = 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right)$$

and

-continued

$$v_{DI} - v_{D3} = T\frac{kn}{q}\ln\left(\frac{i_1}{i_3}\right) = T\frac{kn}{q}\ln\left(\frac{i_1}{\sqrt{i_1 \cdot i_2}}\right) = T\frac{kn}{q}\ln\left(\left(\frac{i_1}{i_2}\right)^{\frac{1}{2}}\right) = 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right).$$

[0032] The values on the right side of the preceding two equalities are identical. A term may be added to the right side of each equality based on Ohm's Law to account for ESR (R_s) of a signal path associated with diode **10**. For example:

$$v_{D3} - v_{D2} = 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right) + (i_3 - i_2) \cdot R_s$$

$$v_{DI} - v_{D3} = 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right) + (i_1 - i_3) \cdot R_s$$

[0033] Solving for R_s in terms of voltages v_{D1}, v_{D2}, and v_{D3}:

$$(v_{DI} - v_{D3}) - (v_{D3} - v_{D2}) = 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right) - 0.5T\frac{kn}{q}\ln\left(\frac{i_1}{i_2}\right) +$$

$$(i_1 - i_3) \cdot R_s - (i_3 - i_2) \cdot R_s$$

$$v_{DI} - v_{D3} - v_{D3} + v_{D2} = (i_1 - i_3 - i_3 + i_2) \cdot R_s$$

$$v_{DI} + v_{D2} - 2v_{D3} = (i_1 + i_2 - 2i_3) \cdot R_s$$

$$R_s = \frac{v_{DI} + v_{D2} - 2v_{D3}}{i_1 + i_2 - 2i_3}$$

[0034] Once R_s is known, the temperature may be determined using a version of Equation A:

$$T = \frac{q(v_1 - v_2 - (i_1 - i_2) \cdot R_s)}{kn \ln\left(\frac{i_1}{i_2}\right)} \qquad \text{[Equation B]}$$

[0035] In some embodiments, the ESR of the signal path associated with diode **10** may be significant. For example, the signal path may be long or a portion of the path may present a significant resistance. It may therefore be desirable to account for the ESR in the determination of the temperature. However, it may be difficult to approximate the ESR and therefore difficult to accurately determine the temperature. The approximation may be difficult because, for example, various portions of the signal path may present different resistivities due to non-uniform heating of the signal path, and/or because the signal path itself (and its associated ESR) may be dynamic due to active switching of diode **10** to various signal paths. In these cases and others, some embodiments of process **60** might provide more accurate results than previously obtained.

[0036] In some embodiments, current i_3 is not equal to a geometric mean of currents i_1 and i_2. Any number of factors may result in this inequality. For example, the currents provided by one or more current sources of system monitoring chip **40** may present a small degree of error, or the inequality may result from a design decision. Equations to calculate ESR and temperature in such circumstances are derived below. The equations may be used in a case that currents i_1, i_2 and i_3 loosely follow a geometric progression. The equations may also be used in cases where i_1, i_2 and i_3 do not follow a geometric progression, and/or where current i_3 corresponds to a geometric mean of currents i_1 and i_2.

[0037] From Equation A, including terms to account for ESR (R_s):

$$(v_{DI} - v_{D3}) - (v_{D3} - v_{D2}) = T\frac{kn}{q}\left(\ln\left(\frac{i_1}{i_3}\right) - \ln\left(\frac{i_3}{i_2}\right)\right) + (i_1 - i_3) \cdot R_s - (i_3 - i_2) \cdot R_s$$

$$(v_{DI} - v_{D3}) - (v_{D3} - v_{D2}) = T\frac{kn}{q}\ln\left(\frac{i_1 i_2}{i_3^2}\right) + (i_1 + i_2 - 2i_3) \cdot R_s$$

$$R_s = \frac{v_{DI} + v_{D2} - 2v_{D3} - T\frac{kn}{q}\ln\left(\frac{i_1 i_2}{i_3^2}\right)}{i_1 + i_2 - 2i_3}$$

[0038] R_s may be substituted into Equation B to derive an equation for temperature as follows:

$$T = \frac{q\left(v_{DI} - v_{D2} - (i_1 - i_2)\left(\frac{v_{DI} + v_{D2} - 2v_{D3} - T\frac{kn}{q}\ln\left(\frac{i_1 i_2}{i_3^2}\right)}{i_1 + i_2 - 2i_3}\right)\right)}{kn\ln\left(\frac{i_1}{i_2}\right)}$$

$$T = \frac{q\left(v_{DI} - v_{D2} - (i_1 - i_2)\left(\frac{v_{DI} + v_{D2} - 2v_{D3}}{i_1 + i_2 - 2i_3}\right)\right)}{kn\ln\left(\frac{i_1}{i_2}\right)} + T\frac{(i_1 - i_2)\left(\frac{\ln\left(\frac{i_1 i_2}{i_3^2}\right)}{i_1 + i_2 - 2i_3}\right)}{\ln\left(\frac{i_1}{i_2}\right)}$$

$$T = \frac{\left(\frac{q\left(v_{DI} - v_{D2} - (i_1 - i_2)\left(\frac{v_{DI} + v_{D2} - 2v_{D3}}{i_1 + i_2 - 2i_3}\right)\right)}{kn\ln\left(\frac{i_1}{i_2}\right)}\right)}{\left(1 - \frac{(i_1 - i_2)\left(\frac{\ln\left(\frac{i_1 i_2}{i_3^2}\right)}{i_1 + i_2 - 2i_3}\right)}{\ln\left(\frac{i_1}{i_2}\right)}\right)}$$

[0039] or, in simpler form:

$$a = \frac{q}{kn}, b = \frac{i_1 - i_2}{i_1 + i_2 - 2i_3}, c = \ln\left(\frac{i_1 i_2}{i_3^2}\right), d = \ln\left(\frac{i_1}{i_2}\right)$$

$$T = \left(\frac{a}{d - bc}\right)(v_{DI} - v_{D2} - b(v_{DI} + v_{D2} - 2v_{D3}))$$

[0040] In some embodiments, currents i_1 and i_2 may be any suitable currents. For example, current i_1 may be substantially equal to the maximum current specification of IC die **20** and current i_2 may be substantially equal to the

minimum current specification of IC die **20**. According to some embodiments, currents i_1, i_2 and i_3 may be transmitted to diode **10** and their associated voltages determined in any order.

[0041] Accuracy of some embodiments may be increased if the temperature of diode **10** and the ESR of the associated signal path are substantially constant during process **60**. This concern may be addressed by transmitting the currents and determining the associated voltages according to a sequence that may compensate for continuously decreasing or continuously increasing temperatures. For example, the sequence i_3-i_2-i_1-i_2-i_3 places the i_2-i_1-i_2 sequence in the shortest time span. The i_3-i_2 and i_2-i_3 sequences are further separated, but the effects thereof on the determination of temperature may offset one another. This sequence requires $(v_{D3}-v_{D1})$ and $(v_{D1}-v_{D3})$ to be inferred. Other sequences may be used, some of which may be symmetrical. Possible sequences also include i_3-i_2-i_3-i_1-i_3 and i_2-i_3-i_1-i_3-i_2, in which the current swings are reduced to the smallest consecutive steps. i_3-i_2-i_1-i_2-i_3

[0042] In some embodiments, the measurements for one sample occur during a time interval smaller than a thermal time constant associated with the varying thermal densities occurring within IC die **20**. Some embodiments minimize input capacitance to allow complete voltage settling following a current switch before voltage determination.

[0043] Some embodiments may allow for two-wire measurements. In this regard, resistances of instrumentation cables may be accounted for by the determined ESR.

[0044] FIG. 6 is a side elevation of system **70** according to some embodiments. System **70** may comprise components of a server platform. System **70** includes IC die **20**, system monitoring chip **40** as described above, memory **80** and motherboard **90**. IC die **20** may comprise a microprocessor.

[0045] Substrate **100** couples electrical contacts **24** of IC die **20** to through-hole pins **105** Pins **105** may carry signals such as power and I/O signals between elements of IC die **20** and external devices. For example, pins **105** may be mounted directly on motherboard **90** or onto a socket (not shown) that is in turn mounted directly to motherboard **90**. System monitoring chip **40** may also be mounted to motherboard **90** and may transmit current signals to diode **10** through motherboard **90** and appropriate ones of pins **105** and electrical contacts **24**.

[0046] Motherboard **90** may also electrically couple memory **80** to IC die **20**. More particularly, motherboard **90** may comprise a memory bus (not shown) that is electrically coupled to pins **105** and to memory **80**. Memory **80** may comprise any type of memory for storing data, such as a Single Data Rate Random Access Memory, a Double Data Rate Random Access Memory, or a Programmable Read Only Memory.

[0047] The several embodiments described herein are solely for the purpose of illustration. The various features described herein need not all be used together, and any one or more of those features may be incorporated in a single embodiment. Some embodiments may include any currently or hereafter-known versions of the elements described herein. Therefore, persons skilled in the art will recognize

from this description that other embodiments may be practiced with various modifications and alterations.

1. A method comprising:

transmitting a first current through a diode;

determining a first voltage across the diode, the first voltage associated with the first current;

transmitting a second current through the diode;

determining a second voltage across the diode, the second voltage associated with the second current;

transmitting a third current through the diode;

determining a third voltage across the diode, the third voltage associated with the third current; and

determining a temperature based at least in part on the first voltage, the second voltage and the third voltages

wherein a magnitude of the third current is substantially equal to a geometric mean of a magnitude of the first current and a magnitude of the second current.

2. A method according to claim 1, wherein determining the temperature comprises:

determining the effective series resistance of a path associated with the diode based at least in part on the first voltage, the second voltage and the third voltage.

3. A method according to claim 1, wherein determining the temperature comprises determining the value of

$q(v_1-v_2-(i_1-i_2)\times R_s)/(kn)\ln(i_1/i_2)$, wherein R_s=is substantially equal to $(v_1+v_2-2v_3)/(i_1+i_2-2\ i_3)$ and corresponds to the effective series resistance, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corresponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

4. (cancelled)

5. A method comprising:

transmitting a first current through a diode;

determining a first voltage across the diode, the first voltage associated with the first current;

transmitting a second current through the diode;

determining a second voltage across the diode the second voltage associated with the second current;

transmitting a third current through the diode:

determining a third voltage across the diode the third voltage associated with the third current, and

determining a temperature based at least in part on $(a/(d-bc))(v_1-v_2-b(v_1+v_2-2\ v_3)$, wherein

$a=q/kn$, $b=(i_1-i_2)/(i_1+i_2-2\ i_3)$, $c=\ln[(i_1i_2)/i_3{}^2]$, and $d=\ln(i_1/i_2)$, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corresponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n

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corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

6. A method according to claim 5, wherein a magnitude of the first current, a magnitude of the third current, and a magnitude of the second current substantially conform to a geometric progression.

7. An apparatus comprising:

a first diode;

a device coupled to the first diode to transmit a first current through the first diode, to determine a first voltage across the first diode, the first voltage associated with the first current, to transmit a second current through the first diode, to determine a second voltage across the first diode, the second voltage associated with the second current, to transmit a third current through the first diode, to determine a third voltage across the first diode, the third voltage associated with the third current, and to determine a temperature of the first diode based at least in part on the first voltage, the second voltage and the third voltage, wherein a magnitude of the third current is substantially equal to a geometric mean of a magnitude of the first current and a magnitude of the second current.

8. An apparatus according to claim 7, the device to determine the temperature by determining the effective series resistance of a path associated with the first diode based at least in part on the first voltage, the second voltage and the third voltage.

9. An apparatus according to claim 7, the device to determine the temperature by determining the value of

$q(v_1-v_2-(i_1-i_2)\times R_s)/(kn)1n(i_1/i_{2}$), wherein $_{Rs}=(v_1+v_22\ v_3)/(i_1+i_2-2\ i_3)$ and corresponds to the effective series resistance, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corresponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

10. (cancelled)

11. An apparatus comprising:

a first diode,

a device coupled to the first diode to transmit a first current through the first diode, to determine a first voltage across the first diode, the first voltage associated with the first current to transmit a second current through the first diode to determine a second voltage across the first diode, the second voltage associated with the second current, to transmit a third current through the first diode, to determine a third voltage across the first diode, the third voltage associated with the third current, and to determine a temperature of the first diode based at least in part on $(a/(d-bc))(v_1-v_2-b(v_1+v_2-2\ v_3)$, wherein

$a=q/kn$, $b=(i_1-i_2)/(i_1+i_2-2\ i_3)$, $c=1n[(i_1i_2/i_3{}^2]$, and $d=1n(i_1/i_2)$, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corre-

sponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

12. An apparatus according to claim 11, wherein a magnitude of the first current, a magnitude of the third current, and a magnitude of the second current substantially conform to a geometric progression.

13. An apparatus according to claim 7, further comprising:

a second diode,

wherein the device is coupled to the second diode to transmit a fourth current through the second diode, to determine a fourth voltage across the second diode, the fourth voltage associated with the fourth current, to transmit a fifth current through the second diode, to determine a fifth voltage across the second diode, the fifth voltage associated with the fifth current, to transmit a sixth current through the second diode, to determine a sixth voltage across the second diode, the sixth voltage associated with the sixth current, and to determine a temperature of the second diode based at least in part on the third voltage, the fourth voltage and the fifth voltage.

14. An apparatus according to claim 13, wherein the first diode and the second diode are integrated into a same substrate.

15. An apparatus according to claim 7, wherein the device comprises an analog-to-digital converter and a microcontroller.

16. An apparatus according to claim 15, wherein the first diode and the device are integrated into a same substrate.

17. A system comprising:

an integrated circuit comprising a first diode;

a device coupled to the first diode to transmit a first current through the first diode, to determine a first voltage across the first diode, the first voltage associated with the first current, to transmit a second current through the first diode, to determine a second voltage across the first diode, the second voltage associated with the second current, to transmit a third current through the first diode, to determine a third voltage across the first diode, the third voltage associated with the third current, and to determine a temperature of the first diode based at least in part on the first voltage, the second voltage and the third voltage, a magnitude of the third current being substantially equal to a geometric mean of a magnitude of the first current and a magnitude of the second current; and

a double data rate memory electrically coupled to the integrated circuit.

18. A system according to claim 17, the device to determine the temperature by determining the effective series resistance of a path associated with the first diode based at least in part on the first voltage, the second voltage and the third voltage.

19. A system according to claim 17, the device to determine the temperature by determining the value of

$q(v_1-v_2-(i_1-i_2)\times R_s)/(kn)1n(i_1/i_2)$, wherein $R_s=(v_1+v_2-2\ i_3)$ and corresponds to the effective series resistance, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corresponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

20. (cancelled)

21. A system according to claim 17, the device to determine the temperature by determining the value of

$(a/(d-bc))(v_1-v_2-b(v_1+v_2-2\ v_3)$, wherein

$a=q/kn$, $b=(i_1-i_2)/(i_1+i_2-2\ i_3)$, $c=1n[(i_1i_2)/i_3^2]$, and $d=1n(i_1/i_2)$, and

wherein v_1 corresponds to the first voltage, v_2 corresponds to the second voltage, v_3 corresponds to the third voltage, i_1 corresponds to the first current, i_2 corresponds to the second current, i_3 corresponds to the third current, k corresponds to Boltzmann's Constant, n corresponds to an ideality factor associated with the diode, and q corresponds to the charge of a electron.

22. (cancelled)

23. A system according to claim 17, wherein the integrated circuit comprises a microprocessor.

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